Surface modification of TiO$_2$
by atmospheric pressure plasma

조상진, 정충경, 부진효
성균관대학교 화학과

To improve surface wettability, each sample was treated by atmospheric pressure plasma (APP) using dielectric barrier discharge (DBD) system. Argon and oxygen gases were used for treatment gas to modify the TiO$_2$ surface by APP with RF power range from 50 to 200 W. Water contact angle was decreased from 20° to 10° with argon only. However, water contact angle was decreased from 20° to <1° with mixture of argon and oxygen. Water contact angle with O$_2$ plasma was lower than water contact angle with Ar plasma at the same RF power. It seems to be increasing the polar force of TiO$_2$ surface. Also, analysis result of X-ray photoelectron spectra (XPS) shows the increase of intensity of O1s shoulder peak, resulting in increasing of surface wettability by APP. Moreover, each water contact angle increased according to increase past time. However, contact angle increase with plasma treatment was lower than without plasma treatment. Additionally, the efficiency of TiO$_2$ photocatalyst was improved by plasma surface-treatment through the degradation experiment of phenol.